

PRODUCT DATA SHEET

# TACFlux® 10-ULR

## Features

- Designed for flip-chip dipping applications
- Suitable for Pb-free alloys
- Ultra-low residue
- Halogen-free
- No-clean

## Introduction

TACFlux® 10-ULR is a halogen-free, no-clean flip-chip dipping flux which is designed to leave a completely benign, clear residue. The reduction in residue optimizes underfill adhesion and decreases possible outgassing during underfill cure.

## Properties

Property	Value	Test Method
Flux Type	RELO	J-STD-004 (IPC-TM-650: 2.3.32 and 2.3.33)
Color	Light Yellow	Visual
Typical Viscosity	1475cps	Brookfield DV-I. 40CPE Spindle @10rpm after 3 mins
Typical Acid Value	39mg KOH/g	Titration
SIR (ohms)	Pass	J-STD-004 (IPC-TM-650: 2.6.3.3 IPC-B-24)
Typical Post Reflow Residual Weight	<5%	TGA Data
Working Life	≥ 8 hr	Customer Experience (Dipping)
Shelf Life	1 year when stored at 0 to 30°C	Viscosity Change/ Microscope Examination

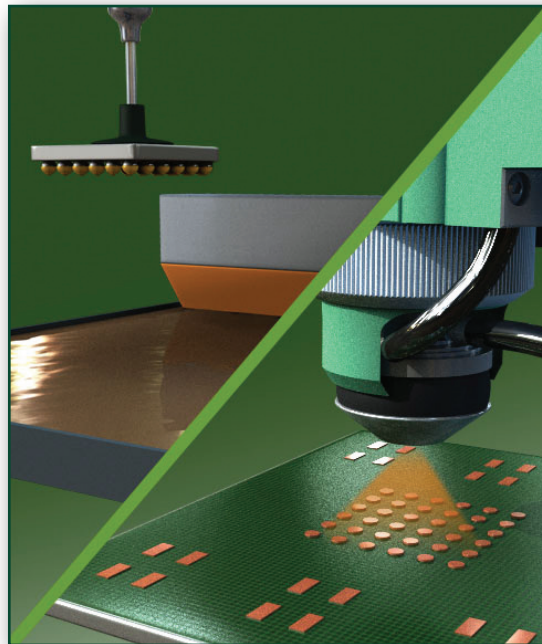
All information is for reference only. Not to be used as incoming product specifications.

## Application

TACFlux® 10-ULR will have strong adhesion to epoxy-based underfill materials, especially epoxy-amine and epoxy-acid based chemistries. TACFlux® 10-ULR should also be suitable for use with many epoxy-anhydride systems.

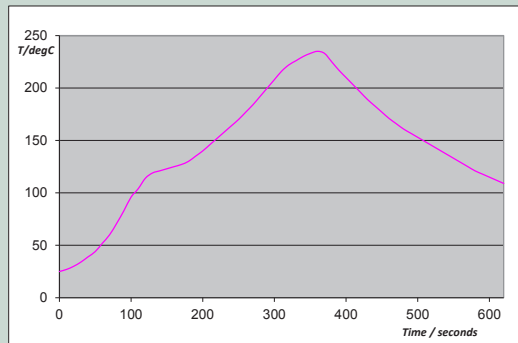
## Cleaning

TACFlux® 010-ULR is designed for no-clean applications. If necessary, the flux can be removed by using a commercially available flux cleaner. Please contact an Indium Corporation Technical Service Engineer for recommendations of cleaners to suit your process needs.



## Reflow

### Recommended Profile:



TACFlux® 10-ULR is intended to be used in a nitrogen reflow environment of 100ppm oxygen or less. Some applications can utilize this material in an air environment, although best results will be obtained in an inert atmosphere. TACFlux® 10-ULR can be used on many surface finishes including immersion Ag, Cu, and AuNi. These surfaces can be soldered with Pb-free alloys, but require nitrogen if reflow temperatures exceed 240°C.

OVER→

Form No. 99056 (A4) R1

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## TACFlux® 10-ULR

### Packaging

TACFlux® 10-ULR is most commonly available in containers from 100g to 3.2kg (1 gallon). Other packaging can be provided to meet specific requirements.

### Storage

TACFlux® 10-ULR containers should be stored at 0 °C to 30 °C for maximum shelf life. TACFlux® 10-ULR should be allowed to reach ambient temperature before use if stored cold.

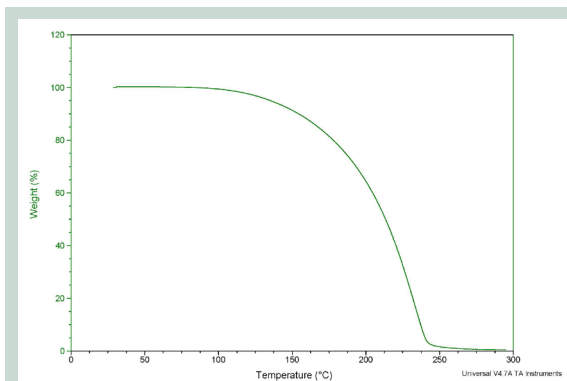
### Technical Support

Indium Corporation sets the industry standard in providing rapid response, on-site technical support for our customers worldwide. Indium Corporation's team of Technical Support Engineers can provide expertise in all aspects of Materials Science and Semiconductor Packaging process applications.

### Safety Data Sheets

The SDS for this product can be found online at <http://www.indium.com/sds>

### Thermogravimetric Analysis (TGA)



TGA was performed at a ramp rate of 10 °C per minute.

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